

c) Amendments to the Claims

Please cancel claims 1-3 and 10-12 without prejudice or disclaimer. A detailed listing of all the claims that are or were on the application is provided.

Claims 1-6 (Cancelled)

7. (Original) A method of forming a deposited film, comprising supplying a source gas into a chamber to form a deposited film on a substrate, and thereafter, introducing a gas for opening to atmosphere into the chamber to return a pressure within the chamber to atmospheric pressure,

wherein a plurality of shut-off valves are provided in series between a gas source of the gas for returning the pressure within the chamber to the atmospheric pressure and the chamber; and

wherein the plurality of shut-off valves are closed to perform film deposition while a source gas is being supplied into the chamber.

8. (Original) The method according to claim 7, wherein a pressure between the plurality of shut-off valves is reduced to perform film deposition.

9. (Original) The method according to claim 7, wherein a space between the plurality of shut-off valves is filled with a non-reactive gas to perform film deposition.--